

Form PTO-1449	U.S. DEPARTMENT OF COMMERCE PATENT AND TRADEMARK OFFICE	ATTY. DOCKET NO. 33019US1	SERIAL NO. <del>10-800450</del> 10-800450
INFORMATION DISCLOSURE CITATION BY APPLICANT (USE SEVERAL SHEETS IF NECESSARY)		APPLICANT: Emmanuel Hadji et al.	
		FILING DATE: Herewith 3-15-04	GROUP ART UNIT: <del>TBD</del> 2826
Page 1 of 1			

U.S. PATENT DOCUMENTS							
Exam. Itl.		Document No.	Date	Name	Class	Subclass	Filing Date
CAL	A	4,848,272	7/1989	Ohmura et al.	118	50.1	
	B	5,013,681	5/1991	Godbey et al.	438	459	
	C	5,363,398	11/1994	Glass et al.			
	D	5,374,564	12/1994	Bruehl			
	E	5,835,521	11/1998	Ramdani et al.	372	50	
	F	5,838,065	11/1998	Hamburgen et al.	257	722	
	G	5,993,677	11/1999	Biasse et al.	216	36	
	H	5,985,687	11/1999	Bowers et al.	438	29	
	I	6,008,110	12/1999	Samata et al.	438	459	
	J	6,013,912	1/2000	Pautrat et al.	250	214.1	
CAL	K	6,046,065	4/2000	Goldstein et al.	372	43	

FOREIGN PATENT DOCUMENTS							
		Document No.	Date	Country	Class	Subclass	Translation
CAL	L	0 578 407	1/1994	EP			

OTHER REFERENCES (Including Author, Title, Date, Pertinent Pages, Etc.)		
CAL	M	Yukari Ishikawa et al., Epitaxy-ready Si/SiO <sub>2</sub> Bragg reflectors by multiple separation-by-implanted-oxygen, Dec. 16, 1996, pages 3881-3883.
	N	E.F. Schubert et al., Giant enhancement of luminescence intensity in Er-doped Si/SiO <sub>2</sub> resonant cavities, Sept. 21, 1992, pages 1381-1383.
	P	R.A. Soref et al., Silicon intersubband lasers, 1998, pages 427-439.
	Q	Richard A. Soref, Prospects for novel si-based optoelectronic devices: unipolar and p-i-p-i lasers, July, 1992, pages 325-329.
	R	Michio Tajima et al., Luminescence due to electron-hole condensation in silicon-on-insulator, August, 1998, pages 2224-2228.
CAL	S	M. Tajima et al., Characterization of bond and etch-back silicon-on-insulator wafers by photoluminescence under ultraviolet excitation, January, 1997, pages 231-233.

Examiner: 	Date Considered 7/24/04
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\*Examiner: Initial if reference considered, regardless of whether citation is in conformance with MPEP 609; Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.